·	Application No.	Applicant(s)
Notice of Allowability	10/606,263	SHARMA, MANISH
	Examiner	Art Unit
	Monica D. Harrison	2813
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to 5/13/05.		
2. The allowed claim(s) is/are <u>1-38</u> .		
3. 🔀 The drawings filed on <u>25 June 2003</u> are accepted by the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some* c) None of the: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
6. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.		
(a) \square including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached		
1) hereto or 2) to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
 DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL. 		
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Attachment(s) 1. ☒ Notice of References Cited (PTO-892)	5. Notice of Informal	Patent Application (PTO-152)
Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summar	
3. Information Disclosure Statements (PTO-1449 or PTO/SB/	Paper No./Mail Da 08), 7. ☐ Examiner's Amend	Iment/Comment
Paper No./Mail Date 4.	8. 🛛 Examiner's Statem	nent of Reasons for Allowance
of Biological Material	9.	
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3.

DETAILED ACTION

1. Applicant's amendment filed 5/13/05 has been entered.

Allowable Subject Matter

2. Claims 1-38 are allowed over the prior art of record.

Reasons For Allowance

The following is an examiner's statement of reasons for allowance:

Applicant's arguments and amendment filed 5/13/05 have been considered and subsequent to an updated search of relevant prior art, examiner acknowledges that

Volfson et al (5,106,461) does not disclose depositing a dielectric coating upon the patterned layer and the remaining photoresist; and ion etching at a low angle relative to the patterned layer to remove the dielectric coated photoresist, the removal of the

photoresist thereby providing at least one self-aligned via contact (claim 1), depositing a

dielectric coating upon the etching exposed surfaces and the photoresist; and ion etching

at a low angle relative to the wafer substrate to remove the dielectric coated photoresist,

the removal of the photoresist thereby providing at least one self-aligned via contact

(claim 12), depositing a second photoresist upon the junction layer and depositing a

second dielectric to coat the etching exposed surfaces and the second photoresist; and ion

etching at a low angle relative to the wafer substrate to remove the dielectric coated

second photoresist, the removal of the second photoresist thereby providing at least one

self-aligned via contact (claim 24) thus finding applicant's arguments persuasive.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

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accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Monica D. Harrison whose telephone number is 571-272-1959. The examiner can normally be reached on M-F 7:00am-3:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Monica D. Harrison

AU 2813

DAVID BLUM PRIMARY EXAMIN

mdh

September 19, 2005